

Substrate: Silicon

Growing Method: CZ

Coating: uncoated

Code	Dia. (mm)	Dia. Tolerance (mm)	Thickness (mm)	Thickness Tolerance (mm)	Grade	S/D	N(Δ N) /PV	Parallelism (arcmin)	Chips (mm)	Bevels (mm)	CA(%)
PSi01C009	13	+0.0/-0.1	2	± 0.1	MONO-N	60-40	5(3)	3	0.35	0.35	95
PSi01D002	20	+0.0/-0.1	2	± 0.1	MONO-N	60-40	5(3)	3	0.35	0.35	95
PSi01E018	25	+0.0/-0.1	2	± 0.1	MONO-N	60-40	5(3)	3	0.35	0.35	95
PSi01E018	50	+0.0/-0.1	3	± 0.1	MONO-N	60-40	5(3)	3	0.35	0.35	95